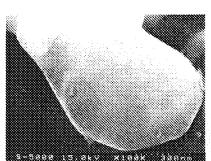
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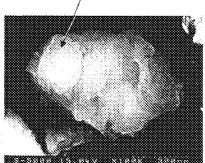
Milling Effects to Ceramic Raw Powders

Micro crack









Re-bonding of fractured pieces

Raw particle

Crystallite size: 740 Å Internal strain: 0.04%

Dry milling for 3 h 345 Å

0.65%

Dry milling for 24 h 286 Å

2.1%

Crush by the dry planetary mill fractures Al₂O₄ particles randomly.

We take advantage of these morphological changes.

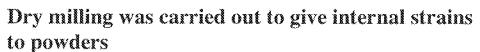
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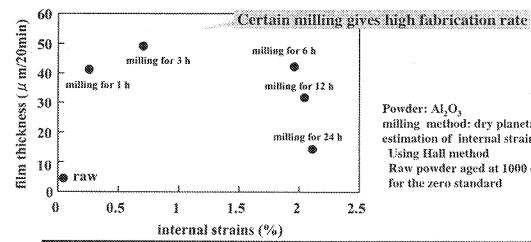
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Milling Effects for Deposition



After that, deposition was carried out.



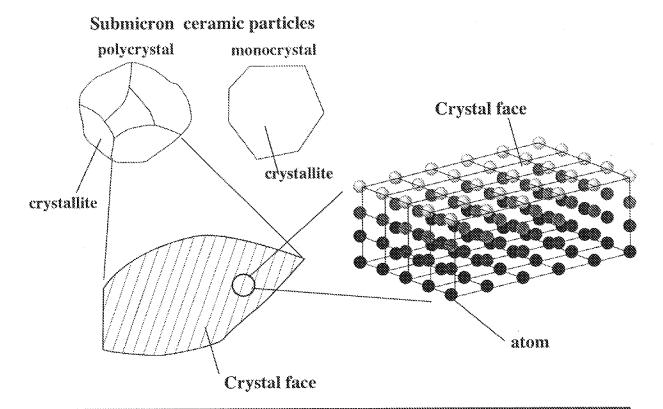
Powder: Al₂O₃ milling method: dry planetary mill estimation of internal strains: Using Hall method Raw powder aged at 1000 degrees C

for the zero standard

Milling is very effective as pre-treatment of powders.



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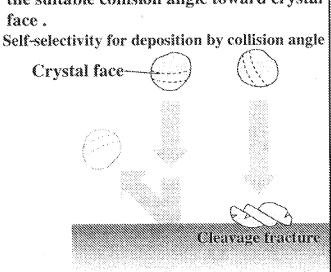
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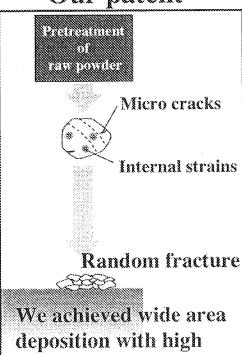
Current technique

Structuring depends on the suitable particle velocity and the suitable collision angle toward crystal face.



Therefore deposition efficiency is very low.

Our patent



depo-rate.

Current Methods

Collision angle provides self-selectivity which particles to be deposited in what rate

- The resulted film has a tendency in its crystal structure.
- · Low deposition efficiency

New Technology

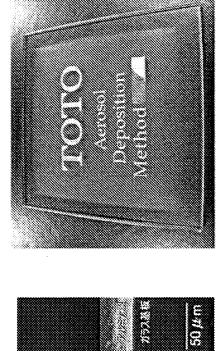
random fractures upon AD process

- □ Collision angle provides less self-selectivity.
- Crystal orientation of AD film quantified by integral intensity raito of specific peaks in XRD profile is very poor and is in good agreement with particles (The deviation is less than 30%).
- · More particles are deposited in good rate (High deposition Efficiency)

In the patent, as one technique, internal strains of the particles caused by milling (pretreatment) enables the random fractures.

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Features of Aerosol Deposition (AD)



Appearance

Fracture cross section

Surface

AD is the rechnique to fabricate thick (Emseveral tens um) commic films

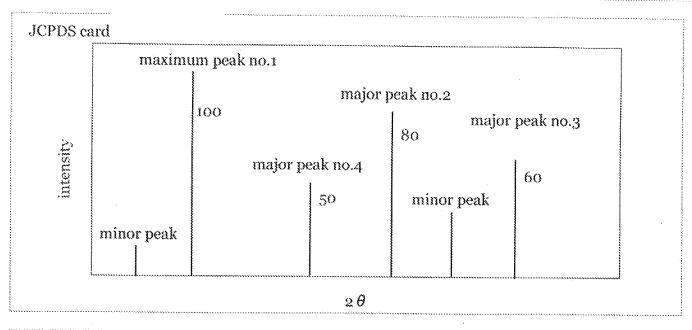
Room temperature process

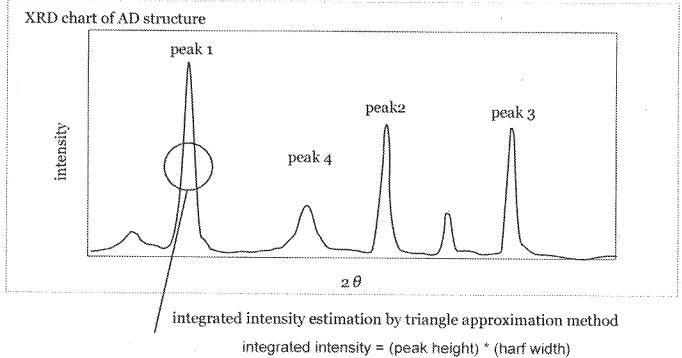
Films are composed of nano-crystal dense structure

Good performance in adhesion, hardness, translucency

EXH BT

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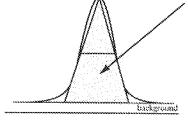




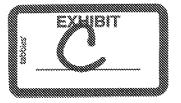
planimetry of this area

peak 1 peak2 peak3 peak4 peak intensity 100 80 60 50 from JCPDS integrated intensity 16.4 mm² 10.6 mm² 20 mm² 4.4 mm² from XRD revised value 100 82 53 22 deviance of 2% 12% 56% oriantation

xxx mm²



no orientation < 30%



(1-82/80)*100 %